

## Toward Orthogonal Self-Assembly of Redox Active Molecules on Pt and Au: Selective Reaction of Disulfide with Au and Isocyanide with Pt

James J. Hickman,<sup>†</sup> Paul E. Laibinis,<sup>‡</sup> David I. Auerbach,<sup>†</sup> Chaofeng Zou,<sup>†</sup>  
Timothy J. Gardner,<sup>†</sup> George M. Whitesides,<sup>†</sup> and Mark S. Wrighton<sup>\*†</sup>

Department of Chemistry, Massachusetts Institute of Technology,  
Cambridge, Massachusetts 02139, and Department of Chemistry, Harvard University,  
Cambridge, Massachusetts 02138

Received November 15, 1991

Surfaces of platinum and gold adsorb 12-ferrocenyldodecyl isocyanide, I, and bis[10-(ferrocenylcarbonyl)-decyl] disulfide, II, and yield self-assembled, redox active monolayers incorporating ferrocene groups. The values of  $E_{1/2}$  for alkylferrocenyl centers from I are  $\sim 300$  mV more negative than acylferrocenyl centers from II. This difference allows easy electrochemical measurement of surface concentrations of ferrocene centers from I and II on Pt or Au. I adsorbs selectively on Pt or Au compared to II, but with different degrees of selectivity. Further, for Pt the selectivity depends on the surface pretreatment. The affinity of II for a Pt surface first exposed to an  $O_2$  plasma (oxidized Pt) is lower than that for a Pt surface exposed first to an  $O_2$  plasma and then to a  $H_2$  plasma (reduced Pt), but the two plasma pretreatments of Pt do not affect the binding of I on this metal. The same two plasma pretreatments of Au do not influence the selectivity for binding I vs II; the selectivity for binding I vs II on Au is  $\sim 8:1$ . By use of the  $O_2$  plasma pretreatment and a 40:1 solution of II:I, self-assembly of II onto Au and I onto Pt can be effected when the two samples are derivatized in the same solution.

We wish to report procedures for formation of self-assembled monolayers that modify Au and Pt electrodes selectively when both are immersed in a common solution containing the isocyanide, I, and the disulfide, II, eq 1. Much work has been reported recently concerning the use of self-assembly methods to functionalize electrode surfaces.<sup>1-11</sup> Relatively little work, however, has been reported concerning the self-assembly of multicomponent systems on different substrates. We have named selec-

tivity of the sort represented in eq 1 "orthogonal self-assembly",<sup>12</sup> meaning that each molecule adsorbs selectively to a different surface. We have previously demonstrated such orthogonal self-assembly for Au and  $Al_2O_3$ : thiols selectively bind to Au, and carboxylic acids bind selectively to  $Al_2O_3$ .<sup>12</sup> Part of the significance of our new findings is that both Pt and Au are useful electrode materials, whereas insulating  $Al_2O_3$  is not. Thus, orthogonal self-assembly using I and II can be exploited to prepare an organized two-component, redox active molecular assembly. A potentially more important application would be to take a single component molecular assembly and use the two different functional groups as "clips" to span the space between two adjacent microelectrodes. Thus, not only would selective functionalization be achieved but also orientation.

Self-assembly of redox active monolayers has been accomplished by immersion of Pt and/or Au into organic solutions of I<sup>13</sup> and/or II.<sup>14,15</sup> The  $E_{1/2}$  for the alkylferrocenyl centers from I is  $\sim 300$  mV more negative than  $E_{1/2}$  for the acylferrocenyl centers from II, allowing easy electrochemical measurement of their surface concentra-

\* Author to whom correspondence should be addressed at M.I.T.

<sup>†</sup> M.I.T.

<sup>‡</sup> Harvard.

(1) Swalen, J. D.; Allara, D. L.; Andrade, J. D.; Chandross, E. A.; Garroff, S.; Israelachvili, I.; McCarthy, T. J.; Murray, R.; Pease, R. F.; Rabolt, J. F.; Wynne, K. J.; Yu, H. *Langmuir* **1987**, *3*, 932.

(2) (a) Polymeropoulos, E. E.; Sagiv, J. *J. Chem. Phys.* **1978**, *69*, 1836. (b) Sagiv, J. *Isr. J. Chem.* **1979**, *18*, 346.

(3) (a) Nuzzo, R. G.; Allara, D. L. *J. Am. Chem. Soc.* **1983**, *105*, 4481. (b) Nuzzo, R. G.; Fusco, F. A.; Allara, D. L. *J. Am. Chem. Soc.* **1987**, *109*, 2358. (c) Porter, M. D.; Bright, T. B.; Allara, D. L.; Chidsey, C. E. D. *J. Am. Chem. Soc.* **1987**, *109*, 3559.

(4) Cotton, T. M.; Kim, J. H.; Uphaus, R. A. *Microchem. J.* **1990**, *42*, 44, and references therein on viologen monolayer electrochemistry.

(5) (a) Li, T. T.-T.; Weaver, M. J. *Am. Chem. Soc.* **1984**, *106*, 6107. (b) Li, T. T.-T.; Weaver, M. J. *Am. Chem. Soc.* **1984**, *106*, 1233.

(6) (a) Bain, C. D.; Whitesides, G. M. *Science* **1988**, *240*, 62. (b) Bain, C. D.; Whitesides, G. M. *J. Am. Chem. Soc.* **1988**, *110*, 3665, 6561. (c) Bain, C. D.; Whitesides, G. M. *Agnew. Chem.* **1989**, *101*, 522. (d) Whitesides, G. M.; Laibinis, P. E. *Langmuir* **1990**, *6*, 87.

(7) (a) Chidsey, C. E. D.; Loiacono, D. N. *Langmuir* **1990**, *6*, 682. (b) Chidsey, C. E. D.; Bertozzi, C. R.; Putvinski, T. M.; Mujisce, A. M. *J. Am. Chem. Soc.* **1990**, *112*, 4301.

(8) (a) Murray, R. W. In *Electroanalytical Chemistry*; Bard, A. J., Ed.; Dekker: New York, 1984; Vol. 13, p 191, and references therein. (b) Hubbard, A. T. *Chem. Rev.* **1988**, *88*, 633.

(9) (a) Tsou, Y. M.; Liu, H. Y.; Bard, A. J. *J. Electrochem. Soc.* **1988**, *135*, 1669. (b) Facci, J. S. *Langmuir* **1987**, *3*, 525.

(10) Widrig, C. A.; Porter, M. D.; Ryan, M. D.; Strein, T. G.; Ewing, A. G. *Anal. Chem.* **1990**, *62*, 1R, and references cited therein on derivatized electrodes.

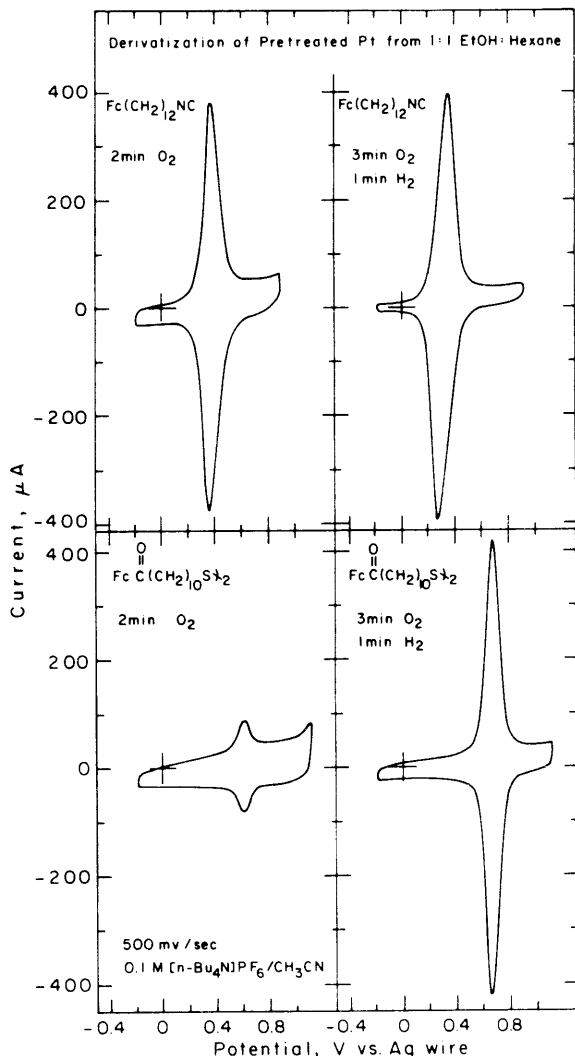
(11) Hickman, J. J.; Zou, C.; Ofer, D.; Harvey, P. D.; Wrighton, M. S.; Laibinis, P. E.; Bain, C. D.; Whitesides, G. M. *J. Am. Chem. Soc.* **1989**, *111*, 7271.

(12) Laibinis, P. E.; Hickman, J. J.; Wrighton, M. S.; Whitesides, G. M. *Science (Washington, D.C.)* **1989**, *245*, 845.

(13) The synthesis of I will be published in the full paper detailing this work.

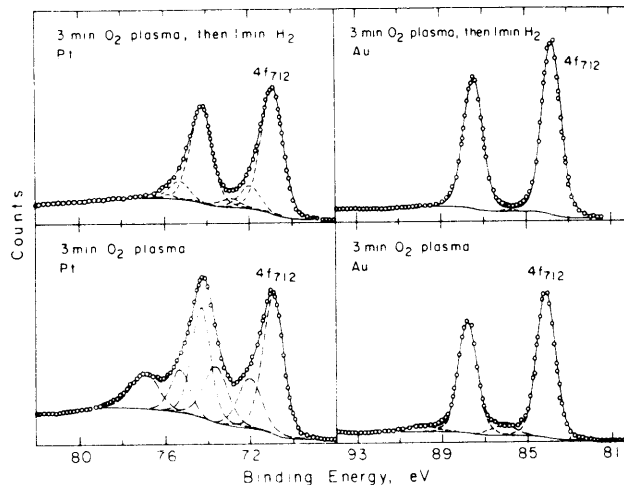
(14) Hickman, J. J.; Ofer, D.; Zou, C.; Laibinis, P. E.; Whitesides, G. M.; Wrighton, M. S. *J. Am. Chem. Soc.* **1991**, *113*, 1128.

(15) Prior to derivatization the e<sup>-</sup>-beam evaporated Au and/or Pt on a Si substrate was pretreated with an  $O_2$  plasma (2-5 min) or with the  $O_2$  plasma followed by a  $H_2$  plasma (1 min). Plasma treatment was done using a Harrick PDC-23G plasma cleaner. The  $O_2$  treatment was at 0.3 Torr at medium power (60 W) and the  $H_2$  treatment was at 0.3 Torr at low power (40 W). Immediately after a plasma pretreatment, the electrodes were derivatized by immersion into a deoxygenated  $5 \times 10^{-6}$  M solution of I or into a  $10^{-4}$  M solution of II in 1:1 EtOH/hexane solvent. Best results for orthogonal self-assembly were achieved using the  $O_2$  plasma pretreatment and a 40:1 solution of II:I in 1:1 EtOH/hexane as solvent at total concentration of adsorbate of  $10^{-4}$  M. Typical derivatization times were 18-48 h.

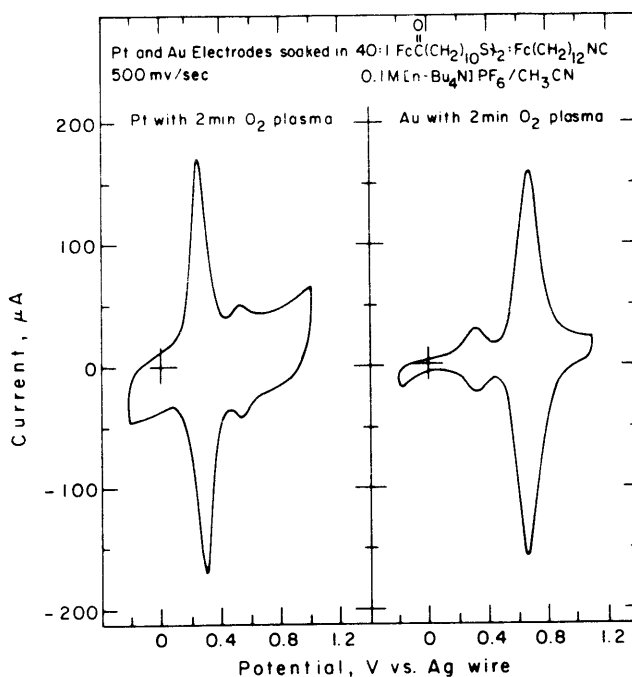


**Figure 1.** Cyclic voltammetry (500 mV/s) in  $\text{CH}_3\text{CN}/0.1 \text{ M } [n\text{-Bu}_4\text{N}]\text{PF}_6$  for Pt electrodes after modification by reaction with  $5 \times 10^{-5} \text{ M I}$  (top) or with  $10^{-4} \text{ M II}$  (bottom) for 18 h in EtOH/hexane (1:1). The data on the left are for Pt electrodes pretreated with a 2-min  $\text{O}_2$  plasma and the data on the right are for Pt electrodes pretreated with a 3-min  $\text{O}_2$  plasma followed by a 1-min  $\text{H}_2$  plasma.

tions even when both species are on the surface. For Au or Pt surfaces pretreated by sequential exposure to an  $\text{O}_2$  plasma (2–5 min) followed a  $\text{H}_2$  plasma (1 min), we find that I or II form a durable, redox active monolayer ( $(3\text{--}5) \times 10^{-10} \text{ mol/cm}^2$ ) on either Pt or Au. However, pretreatment with only the  $\text{O}_2$  plasma suppresses the uptake of the disulfide, II, on Pt, while not affecting the uptake of the isocyanide, I, Figure 1. The pretreatment procedure for Au involving only the  $\text{O}_2$  plasma gives the same response to I or II as found when pretreatment involves the sequential  $\text{O}_2$  and  $\text{H}_2$  plasmas. X-ray photoelectron



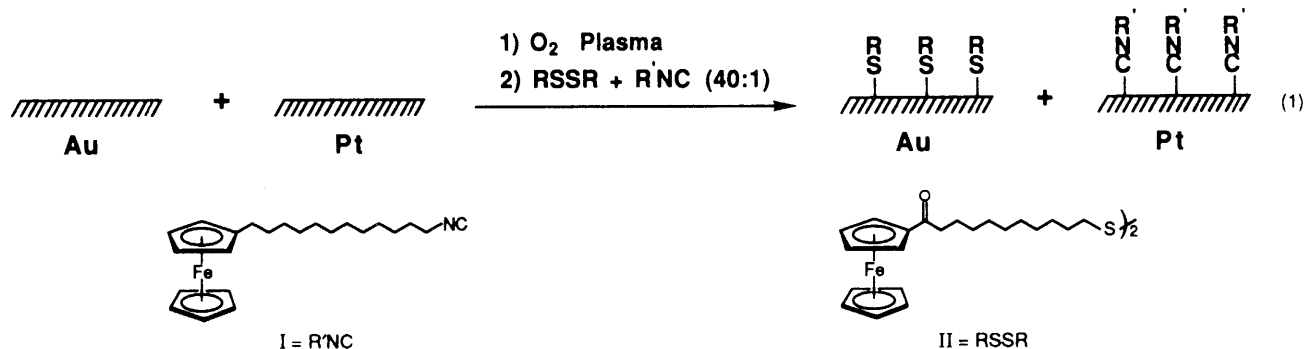
**Figure 2.** Comparison of XPS data for Pt and Au pretreated with a 3-min  $\text{O}_2$  plasma or with a 3-min  $\text{O}_2$  plasma followed by a 1-min  $\text{H}_2$  plasma.



**Figure 3.** Comparison of cyclic voltammetry (500 mV/s) in  $\text{CH}_3\text{CN}/0.1 \text{ M } [n\text{-Bu}_4\text{N}]\text{PF}_6$  for oxidized (2-min  $\text{O}_2$  plasma pretreatment) Pt and Au electrodes after derivatization in EtOH/hexane (1:1) solution containing  $1 \times 10^{-4} \text{ M II}$  and  $2.5 \times 10^{-6} \text{ M I}$  for 18 h.

spectra (XPS) in the  $4f_{7/2}$  region, Figure 2, show high binding energy peaks consistent with the presence of a Au or Pt oxide after the  $\text{O}_2$  plasma pretreatment which is removed by the  $\text{H}_2$  plasma pretreatment.<sup>16</sup>

Ten independent comparisons show that the reduced



Pt (O<sub>2</sub> plasma followed by H<sub>2</sub> plasma) yields about 10 times the coverage of redox active material as does the oxidized Pt (O<sub>2</sub> plasma only) when reacting both surfaces in the same solution of II, Figure 1. Importantly, oxidized and reduced Pt derivatized with only I show the same coverage,  $\sim(4 \pm 1) \times 10^{-10}$  mol/cm<sup>2</sup>. XPS analysis of oxidized Pt functionalized with I shows high binding energy Pt 4f<sub>7/2</sub> peaks, consistent with retention of the oxidized surface. In contrast, XPS of oxidized Au after reaction with I or II shows no detectable high binding energy peaks, consistent with loss of the Au oxide. Electrochemically formed Au oxide has also been shown to be reactive toward other surface modification reagents.<sup>17</sup>

Electrochemical analyses of pretreated Pt and Au after reaction with mixtures of I and II show that the isocyanide, I, is always more competitively adsorbed than the disulfide, II, but a sufficiently large ratio of II:I in solution will yield selective uptake of II. The reduced and oxidized Au both give a preference of I vs II of 8:1. Reduced and oxidized Pt, however, have different preferences for I vs II, since oxidized Pt is nearly inert to II. The preferences for uptake of I vs II on oxidized and reduced Pt are  $\sim 200$ :

---

(16) XPS was done using an SSL 100 spectrometer. Samples were attached to the stage via metal clips. The lowest energy Pt 4f<sub>7/2</sub> peak was taken to be Pt(0) and the lowest energy Au 4f<sub>7/2</sub> peak was taken to be Au(0), and they were monitored as the reference to correct any peak shifts due to sample charging (Au(0) 4f<sub>7/2</sub> is at 84.0 eV and Pt(0) 4f<sub>7/2</sub> is at 71.0 eV binding energy). The X-ray line used for excitation was the Al K $\alpha$  line at 1486.6 eV. For a general reference, see: *Handbook of X-ray Photoelectron Spectroscopy*; Perkin-Elmer Corp.: Eden Prairie, MN, 1979.

(17) Fischer, A. B.; Wrighton, M. S.; Umana, M.; Murray, R. W. *J. Am. Chem. Soc.* **1979**, *101*, 3442.

I and  $\sim 20$ :1, respectively. Thus, pretreatment of Pt and Au with only the O<sub>2</sub> plasma is predicted to give the highest degree of orthogonal self-assembly by reaction with I and II with Pt and Au.

By using a 40:1 ratio of II:I in solution and the O<sub>2</sub> plasma pretreatment of Au and Pt, we have demonstrated selective functionalization of Pt with I and selective functionalization of Au with II when derivatized in the same solution of I and II. The self-assembly yields a 1:10 and 10:1 ratio of alkylferrocenyl/acylferrocenyl centers on Au and Pt, respectively, Figure 3. The total coverage of ferrocene centers is always  $\sim(4 \pm 1) \times 10^{-10}$  mol/cm<sup>2</sup>, or about one monolayer. Changing the ratio of I and II in solution changes the ratio of the two different centers on the Au and Pt surfaces in a manner consistent with a competitive reaction of I and II. Further studies are underway to establish the scope of orthogonal self-assembly on Pt and Au, in order to functionalize microelectrode arrays<sup>12,13</sup> with a variety of redox centers.

**Acknowledgment.** We thank the Office of Naval Research and the Defense Advanced Research Projects Agency for partial support of this research. We acknowledge use of XPS and Auger facilities acquired through the joint Harvard/M.I.T. University Research Initiative funded by the Defense Advanced Research Projects Agency. Support from the TRW Corp. to D.I.A. as a TRW Scholar at MIT is also gratefully acknowledged.

**Registry No.** I, 138180-62-8; II, 131832-59-2; Pt, 7440-06-4; Au, 7440-57-5; H<sub>2</sub>, 1333-74-0; O<sub>2</sub>, 7782-44-7; CH<sub>3</sub>CH<sub>2</sub>OH, 64-17-5; *n*-C<sub>6</sub>H<sub>14</sub>, 110-54-3; CH<sub>3</sub>CN, 75-05-8; [*n*-Bu<sub>4</sub>N]PF<sub>6</sub>, 3109-63-5.